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كلية المستقبل الجامعة قسم الفيزياء الطبية المرحلة الثانية أشباه موصلات

What is Junction Breakdown?

In the *ideal PN junction* device, when a reverse bias voltage is applied, a small reverse bias current flow through the device. This reverse current remains very small until a critical voltage is reached, at which point the current suddenly increases. This sudden increase in current is referred to as the junction breakdown

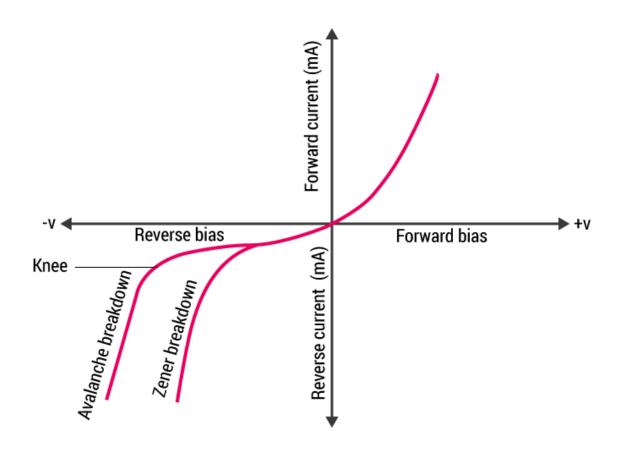
General Breakdown Characteristics

- The maximum reverse bias voltage that can be applied to a p-n diode is limited by breakdown
- Breakdown is characterized by the rapid increase of the current under reverse bias
- The corresponding applied voltage is referred to as the breakdown voltage

Types of Junction Breakdown

There are two physical mechanisms which give rise to the reverse bias breakdown.

- Zener Effect (Zener Breakdown)
- Avalanche Effect (Avalanche Breakdown)



Ideal Diode Equation

 Empirical fit for both the negative and positive I-V of a diode when the magnitude of the applied voltage is reasonably small.

$$I_D = I_S \left(e^{\frac{qV_D}{nkT}} - 1 \right)$$

Ideal Diode Equation

Where

 $\rm I_{\rm D}$ and $\rm V_{\rm D}$ are the diode current and voltage, respectively

q is the charge on the electron

n is the ideality factor: n = 1 for indirect semiconductors (Si, Ge, etc.)

n = 2 for direct semiconductors (GaAs, InP, etc.)

k is Boltzmann's constant

T is temperature in Kelvin

kT/q is also known as V_{th} , the thermal voltage. At 300K (room temperature), kT/q = 25.9 mV

Simplification

When V_D is negative

$$I_D \sim -I_S$$

When V_D is positive

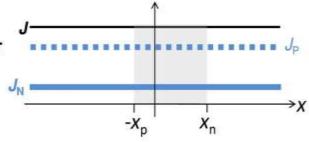
$$I_D \sim I_S e^{\frac{qV_D}{nkT}}$$

General Narrow-Base Diode I-V

- Define $W_{\rm p}$ and $W_{\rm N}$ to be the widths of the quasi-neutral regions.
- If <u>both sides</u> of a pn junction are narrow (i.e. much shorter than the minority carrier diffusion lengths in the respective regions):

$$I = qAn_i^2 \left[\frac{D_P}{W_N' N_D} + \frac{D_N}{W_P' N_A} \right] \left(e^{qV_A/kT} - 1 \right) = I_0 \left(e^{qV_A/kT} - 1 \right)$$

e.g. if hole injection into the n side is greater than electron injection into the p side:



Charge Control Model Summary

Under forward bias, minority-carrier charge is stored in the quasi-neutral regions of a pn diode.

- Long base:
$$Q_N = -qA \frac{n_i^2}{N_A} \left(e^{qV_A/kT} - 1 \right) L_N$$

$$Q_P = qA \frac{n_i^2}{N_D} \left(e^{qV_A/kT} - 1 \right) \mathcal{L}_P$$

- Narrow base:
$$Q_N = -qA \frac{1}{2} \frac{n_i^2}{N_A} (e^{qV_A/kT} - 1) V_P'$$

$$Q_{P} = qA \frac{1}{2} \frac{n_{i}^{2}}{N_{D}} \left(e^{qV_{A}/kT} - 1 \right) V_{N}'$$